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Oxo Ligand Silylation in a Uranyl β -Ketoiminate Complex

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The microbial reduction of the uranyl ion (UO₂²⁺) to U(IV) is a vital component of the environmental remediation of legacy waste sites.^{1,2} This process requires the functionalization and/or substitution of the normally inert uranyl oxo ligands. However, there is little evidence available for the mechanism of reduction,^{3,4} and model systems are scarce.^{5,6} In one recent example, oxo ligand silylation in uranyl was achieved by deprotonation of UO₂(THF)(H₂L) (L = "Pacmac" polypyrrolic macrocycle), ultimately resulting in the formation of a U(V) silyloxide complex [UO(OSiMe₃)(THF)Fe₂I₂L].⁷ During the reaction, an intermediate species, UO2(THF)(K2L), is both reduced and silylated by HN{SiMe₃}₂ to generate the final product.^{8,9} The ability of HN{SiMe₃}₂ to act as a reducing agent in this system is surprising, given the relatively small oxidation potential of the uranyl ion $(-0.35 \text{ V for } UO_2^{2+}(\text{aq}) \text{ vs } Fc/Fc^+).^{10}$ Herein we report the synthesis and characterization of a novel uranyl(V) bis-silyloxide complex, namely U(OSiMe₃)₂I₂(Aracnac), derived from the uranyl ion and Me₃SiI, and provide a redox-based rationale for why oxo ligand silvlation occurs concomitant with uranvl reduction. Me₃SiX reagents have long been employed for oxo ligand substitution in transition metal synthesis, 11 but only one example is previously known for uranyl.12

Addition of excess Me₃SiI to UO₂(^{Ar}acnac)₂ (1) (^{Ar}acnac = ArNC(Ph)CHC(Ph)O, Ar = 3,5-'Bu₂C₆H₃) results in the formation of U(OSiMe₃)₂I₂(^{Ar}acnac) (2), which can be isolated from hexanes as a black crystalline solid in 42% yield (eq 1). Complex **2** is formed by concurrent reduction of the uranium center and silylation of *both* oxo ligands. Additionally, one of the ^{Ar}acnac ligands is replaced by two iodide ligands. The ¹H NMR spectrum of **2** in tol- d_8 exhibits broad singlets at 0.63 ppm and 4.68 ppm, in a 1:1 ratio, assignable to the 'Bu and Me₃Si protons, respectively. Its NIR spectrum (see the Supporting Information) is similar to those observed for other U(V) compounds, ^{13,14} supporting the presence of a 5f¹ ion, while elemental analysis is also consistent with the proposed formulation. The reaction also proceeds in CH₂Cl₂, but the isolated yields are lower.

The solid-state molecular structure of **2** is shown in Figure 1. Complex **2** exhibits a distorted octahedral geometry with a *trans* arrangement of the oxo-derived silyloxide ligands. Its U–O(SiMe₃) bond lengths (U1–O1 = 1.996(5) Å and U1–O2 = 1.986(5) Å) are significantly longer than a typical uranyl U–O(oxo) bond (ca. 1.76 Å) but are comparable to the U–O(SiMe₃) bond length observed in [UO(OSiMe₃)(THF)Fe₂I₂L] (1.993(4) Å). In addition, the O–Si bond lengths in **2** (O1–Si1 = 1.687(6) Å, O2–Si2 = 1.682(6) Å) are consistent with other oxo-derived silyloxides. Is.16

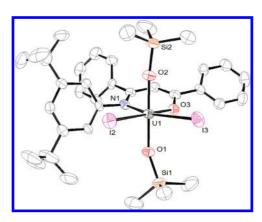


Figure 1. Molecular structure of $U(OSiMe_3)_2I_2(^{Ar}acnac)$ (2) with 50% probability ellipsoids. Selected bond lengths (Å) and angles (deg): U1-O1 = 1.996(5), U1-O2 = 1.986(5), U1-O3 = 2.154(5), U1-N1 = 2.379(7), U1-I2 = 2.9902(7), U1-I3 = 2.9863(7), O1-Si1 = 1.687(6), O2-Si2 = 1.682(6), O1-U1-O2 = 179.1(2).

To confirm the fate of the missing β -ketoiminate ligand in **2**, the reaction between **1** and Me₃SiI was followed by ¹H NMR spectroscopy. This revealed the generation of ArNC(Ph)CHC-(Ph)OSiMe₃, the product of [Aracnac] abstraction by Me₃Si⁺, during the formation of **2**. The spectral properties of ArNC(Ph)CHC(Ph)OSiMe₃ were corroborated by comparison with material prepared independently, via reaction of Na(Aracnac) with 1 equiv of Me₃SiCl (see the Supporting Information).

We have also endeavored to determine the identity of the reducing agent involved in the transformation. Previously, we had shown that coordination of $B(C_6F_5)_3$ to an oxo ligand in 1 forms UO(OB{C₆F₅}₃)(Aracnac)₂ and dramatically changes the uranyl reduction potential from -1.35 to -0.78 V (vs Fc/Fc⁺). ¹⁷ A similar effect may also be operative during formation of 2; i.e., coordination of the strongly Lewis acidic Me₃Si⁺ to the oxo ligands of 1 results in an increase of the U⁶⁺/U⁵⁺ oxidation potential. However, because of the inclusion of two Me₃Si⁺ groups, the affect would be greater than that in the $B(C_6F_5)_3$ example. As a result, the U^{6+}/U^{5+} redox potential may rise above that of I⁻/I₂, resulting in the oxidation of I⁻ and formation of iodine. To assess this hypothesis we performed the reaction of 1 with Me₃SiI in the presence of Ph₃P. The latter forms a phosphonium salt, Ph₃PI₂, with I₂, ¹⁸ which can be easily separated from the reaction mixture. Gratifyingly, the reaction of a mixture of 1 and Me₃SiI with Ph₃P leads to the rapid deposition of a yellow solid. This material was collected and identified as Ph₃PI₂ by comparison of its ³¹P NMR and UV-vis spectra with the independently prepared material.¹⁸

To further probe the oxo ligand silylation of uranyl we investigated the reaction of 1 with other Me_3Si^+ sources. Addition of excess Me_3SiX (X = OTf, Cl) to 1 in toluene leads to the isolation of $UO_2(OTf)_2(^{Ar}acnacH)_2(Et_2O)$ (3) and $UO_2Cl_2(^{Ar}acnacH)_2$ (4), respectively, in moderate yields (eq 2). No evidence for the formation of an oxo functionalized complex was observed in any

of these transformations. Complexes 3 and 4 can also be prepared by reaction of 1 with triflic anhydride or SOCl₂, respectively. Alternately, 3 and 4 can be synthesized simply by addition of 2 equiv of (Aracnac)H to UO2(OTf)2 or UO2Cl2(THF)3 (see the Supporting Information). The ¹H NMR spectra of **3** and **4** contain broad singlets at 13.02 ppm and 13.28 ppm, respectively, assignable to the amine proton of the (Aracnac)H ligand. The solid-state molecular structure of 3 was determined by X-ray crystallography, demonstrating a pentagonal bipyramidal geometry about the uranium center and an η^1 binding mode for the two (Aracnac)H ligands (see the Supporting Information). Also coordinated to the uranyl equatorial plane are two OTf - anions and a molecule of diethyl ether.

1
$$\xrightarrow{\text{xs Me}_3\text{SiX}}$$
 Ph $\xrightarrow{\text{Ph}}$ Ph $\xrightarrow{\text{Ph}}$ Ph $\xrightarrow{\text{O}}$ Ph (2) $\xrightarrow{\text{COEt}_2\text{ln}}$ Ar $\xrightarrow{\text{X = CI, OTf}}$ Ar $\xrightarrow{\text{X = OTf, n = 1, 3; X = CI, n = 0, 4}}$

The NH protons in complexes 3 and 4 are probably derived from solvent decomposition, which may occur via Friedel-Crafts silylation. 19 This subsequently generates the required equivalent of HX. This unwanted reaction pathway is probably also occurring during the formation of 2, as at longer reaction times a broad singlet at 13.14 ppm is observed in the ¹H NMR spectrum of the crude reaction mixture. This resonance is assignable to the amine proton of the (Aracnac)H ligand in UO₂I₂(AracnacH)₂ (5). However, this is only a minor pathway, and 5 is not formed in significant amounts. Complex 5 can also be made by addition of 2 equiv of H(Aracnac) to UO₂I₂(THF)₃, facilitating its complete characterization.

The difference in reaction outcomes between Me₃SiI and Me₃SiX (X = OTf, Cl) probably derives from the reducing ability of the anion, which is greatest for I-. However, the relative strengths of the Si-X bonds may also play a role. In particular, the bond dissociation energies (BDEs) of the Si-Cl bond (113 kcal/mol in Me₃SiCl) or the Si-O bond (e.g., 123 kcal/mol in Me₃SiOMe) are much larger than the Si–I BDEs in Me₃SiI (77 kcal/mol).^{20,21} The formation of a strong Si-O bond is also a factor in driving the formation of 2, as no reaction is observed between 1 and MeI (C-I = 55 kcal/mol).²² To further explore the importance of BDEs we also reacted complex 1 with Me₃SiSiMe₃ (Si-Si = 81 kcal/mol), Ph₃Si-H (Si-H, 89 kcal/mol), and Et₃Si-H (Si-H, 92 kcal/mol).²⁰ However, according to ¹H NMR spectroscopy, no reaction occurred with these substrates, which is unexpected given that R₃SiH is anticipated to be a better reducing agent than Me₃SiI.

Finally, we have revisited the preparation of UX₄(MeCN)₄ (X = Cl, Br, I) via addition of Me₃SiX to UO₂I₂(THF)₃ (eq 3), which was first reported by Ephritikhine and co-workers. 12 We hypothesized that this transformation proceeded in a manner analogous to the formation of 2 and that iodine was generated as a byproduct. To test for I₂ formation, Ph₃P was added to the supernatant produced by the reaction of Me₃SiCl with UO₂I₂(THF)₃. This led to the isolation of a yellow powder, which was identified as Ph₃PI₂ by ³¹P NMR spectroscopy (eq 3), confirming the generation of I₂ during the formation of UCl₄. Thus it seems likely that UCl₄(MeCN)₄ is formed via a silyloxide intermediate similar to 2. The fate of the uranyl oxo ligands was not determined, but they are probably converted into Me₃SiOSiMe₃.²³

$$\begin{array}{c} \text{UO}_2 \text{I}_2 (\text{THF})_3 & \xrightarrow{\text{1) xs TMSCI}} & \text{UCI}_4 (\text{MeCN})_4 + \text{Ph}_3 \text{Pl}_2 & (3) \\ & & \text{2) PPh}_3 & & + 2 \, \text{Me}_3 \text{SiOSiMe}_3 \\ & & \text{MeCN} \end{array}$$

In conclusion, we report that oxo functionalization of a uranyl(VI) complex with Me₃SiI is concomitant with oxidation of I⁻ and formation of a U⁵⁺ center. It appears that coordination of Me₃Si⁺ to the uranyl oxo ligand decreases the uranium reduction potential, making the U⁶⁺ ion a better oxidant. The modulation of the U⁶⁺/ U⁵⁺ redox potential by oxo functionalization may explain previous uranyl silylation chemistry, in particular the results of Arnold and co-workers who invoke a K+-functionalized uranyl complex during the reductive silylation of UO₂(THF)(H₂L).⁷ Most importantly, reductive silylation appears to be a general phenomenon for the uranyl ion, and further study of this transformation could lead to novel treatment strategies for uranium-contaminated soil and groundwater.

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Supporting Information Available: X-ray crystallographic details (CIF) of 2 and 3; IR spectra for 2-5; UV/vis spectra of 2 and Ph₃PI₂; NMR spectra for complexes 2-5, complete refs 1 and 2. This material is available free of charge via the Internet at http://pubs.acs.org.

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